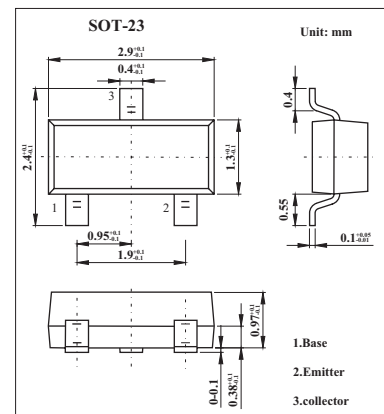


NPN Epitaxial Planar Silicon Transistor

2SC4695

■ Features

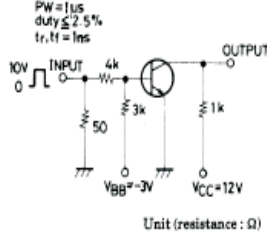
- Adoption of FBET process.
- High DC current gain.
- High V_{EBO} ($V_{EBO} \geq 25V$).
- High reverse h_{FE} (150 typ).
- Small ON resistance [$R_{on}=1W$ ($I_B=5mA$)].

■ Absolute Maximum Ratings $T_a = 25^\circ C$

Parameter	Symbol	Rating	Unit
Collector-base voltage	V_{CBO}	50	V
Collector-emitter voltage	V_{CEO}	20	V
Emitter-base voltage	V_{EBO}	25	V
Collector current	I_C	500	mA
Collector current (pulse)	I_{CP}	800	mA
Base current	I_B	100	mA
Collector dissipation	P_C	250	mW
Junction temperature	T_j	150	$^\circ C$
Storage temperature	T_{stg}	-55 to +150	$^\circ C$

2SC4695

■ Electrical Characteristics Ta = 25°C

Parameter	Symbol	Testconditons	Min	Typ	Max	Unit
Collector cutoff current	ICBO	V _{CB} = 40V, I _E =0			0.1	μA
Emitter cutoff current	IEBO	V _{EB} = 20V, I _C =0			0.1	μA
DC current gain	h _{FE}	V _{CE} = 5V, I _C = 10mA	300		1200	
Gain bandwidth product	f _T	V _{CE} = 10V, I _C = 10mA		250		MHz
Output capacitance	C _{ob}	V _{CB} = 10V, f = 1.0MHz		3.6		pF
Collector-emitter saturation voltage	V _{CE(sat)}	I _C = 100mA, I _B = 2mA		0.12	0.5	V
Base-emitter saturation voltage	V _{BE(sat)}	I _C = 100mA, I _B = 2mA		0.85	1.2	V
Collector-base breakdown voltage	V _{(BR)CBO}	I _C = 10μA, I _E = 0	50			V
Collector-emitter breakdown voltage	V _{(BR)CEO}	I _C = 1mA, R _{BE} = ∞	20			V
Emitter-base breakdown voltage	V _{(BR)EBO}	I _E = 10μA, I _C = 0	25			V
Turn-on time	t _{on}	 PW = 1μs duty ≤ 2.5% t_r, t_f = 1ns Unit (resistance : Ω)		135		ns
Storage time	t _{stg}			450		ns
Fall time	t _f			100		ns

■ Marking

Marking	WT
---------	----